



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

October 25, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG851690940

LABORATORY GROWN DIAMOND

EMERALD CUT

8.06 X 5.48 X 3.57 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.51 CARAT

E

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



LG851690940

Report verification at igi.org

PROPORTIONS

Thin

62%

13.5%

50.5%

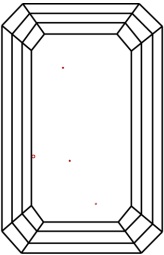
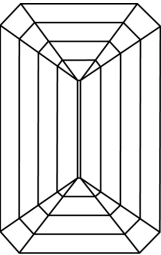
65.1%

Long



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

IGI



© IGI 2020, International Gemological Institute

FD - 10 20

LABORATORY GROWN DIAMOND REPORT



October 25, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG851690940

LABORATORY GROWN DIAMOND

EMERALD CUT

8.06 X 5.48 X 3.57 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.51 CARAT

E

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



IGI



© IGI 2020, International Gemological Institute

FD - 10 20

October 25, 2026

IGI Report No LG851690940

EMERALD CUT

8.06 X 5.48 X 3.57 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Girdle

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.51 CARAT

E

VS 1

65.1%

62%

Thin

Long

EXCELLENT

EXCELLENT

NONE

IGI LG851690940

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa